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<b>REQUEST FOR CONTINUED EXAMINATION (RCE) TRANSMITTAL</b> Address to: Commissioner for Patents Box RCE Washington, DC 20231	Application Number	09/633,132
	Filing Date	August 4, 2000
	First Named Inventor	Cem Basceri
	Group Art Unit	2815
	Examiner Name	E. Lee
	Attorney Docket No.	M4065.0139/P139-A

This is a Request for Continued Examination (RCE) under 37 CFR 1.114 of the above-identified application.

Request for Continued Examination (RCE) practice under 37 CFR 1.114 does not apply to any utility or plant application filed prior to June 8, 1995, or to any design application. See Instruction Sheet for RCEs (not to be submitted to the USPTO) on page 2.

## 1. Submission required under 37 CFR 1.114

a. ☐ Previously submittedi. ☐ Consider the amendment(s)/reply under 37 CFR 1.116 previously filed on \_\_\_\_\_  
(Any unentered amendment(s) referred to above will be entered).ii. ☐ Consider the arguments in the Appeal Brief or Reply Brief previously filed on \_\_\_\_\_iii. ☐ Other \_\_\_\_\_b. ☒ Enclosedi. ☒ Amendment/Replyii. ☐ Affidavit(s)/Declaration(s)iii. ☐ Information Disclosure Statement (IDS)iv. ☐ Other \_\_\_\_\_

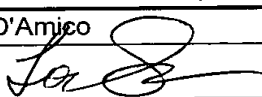
## 2. Miscellaneous

a. ☐ Suspension of action on the above-identified application is requested under 37 CFR 1.103(c) for a period of \_\_\_\_\_ months. (Period of suspension shall not exceed 3 months; Fee under 37 CFR 1.17(l) required)b. ☐ Other \_\_\_\_\_

## 3. Fees The RCE fee under 37 CFR 1.17 (e) is required by 37 CFR 1.114 when the RCE is filed.

a. ☐ The Director is hereby authorized to charge the following fees, or credit any overpayments, to Deposit Account No. \_\_\_\_\_i. ☒ RCE fee required under 37 CFR 1.17(e)ii. ☒ Extension of time fee (37 CFR 1.136 and 1.17)iii. ☐ Other \_\_\_\_\_b. ☒ Check in the amount of \$ 850.00 enclosedc. ☐ Payment by credit card (Form PTO-2038 enclosed)

## SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT REQUIRED

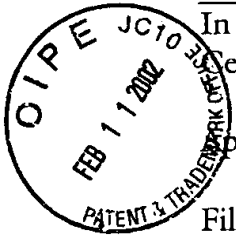
Name (Print/Type)	Thomas J. D'Amico	Registration No. (Attorney/Agent)	28,371
Signature		Date	February 11, 2002

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



In re Patent Application of:

Em Basceri

Application No.: 09/633,132

Filed: August 4, 2000

Group Art Unit: 2815

Examiner: E. Lee

For: METHOD FOR IMPROVING THE  
SIDEWALL STOICHIOMETRY OF THIN  
FILM CAPACITORS

#11/C  
Amclt  
O. McMillan  
2/19/02  
RECEIVED  
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TECHNOLOGY CENTER 28000

AMENDMENT

Box AF  
Commissioner for Patents  
Washington, DC 20231

Dear Sir:

This amendment is being filed concurrently with a request for continued examination (RCE). Please amend the above identified U.S. Patent application as follows:

In the Claims

SUB DI  
C1

39. (Second Amended) A capacitor comprising:

a material layer having a first level and a second level, said first and second levels being connected by a sidewall region between said first and second levels; and

(a doped BST high dielectric constant thin film material deposited on at least one said sidewall region) (said deposited BST thin film material) having a post deposition doping such that the stoichiometry of said BST high dielectric thin film material is substantially uniform at least at said sidewall region.)